



## Supplementary Materials

# Femtosecond Laser-Induced Nano-Joining of Volatile Tellurium Nanotube Memristor

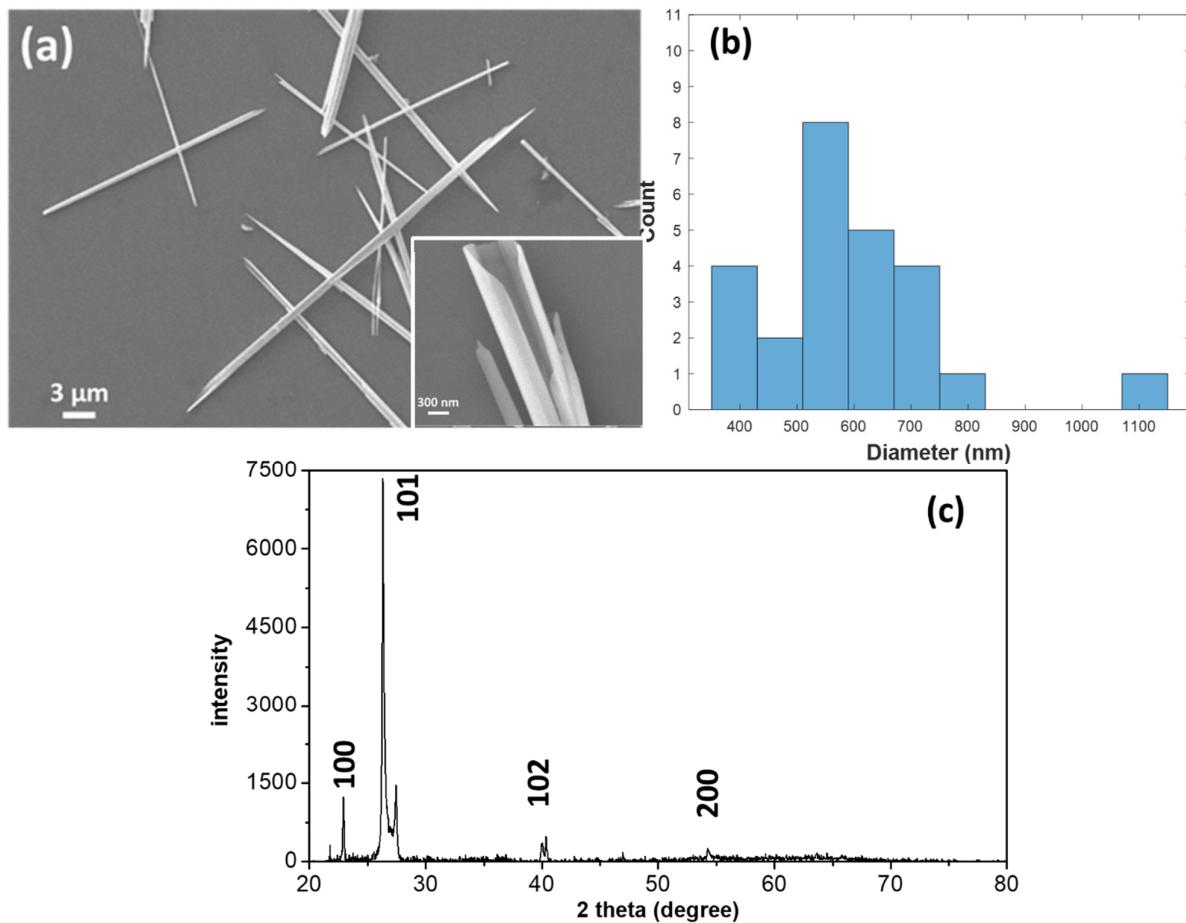
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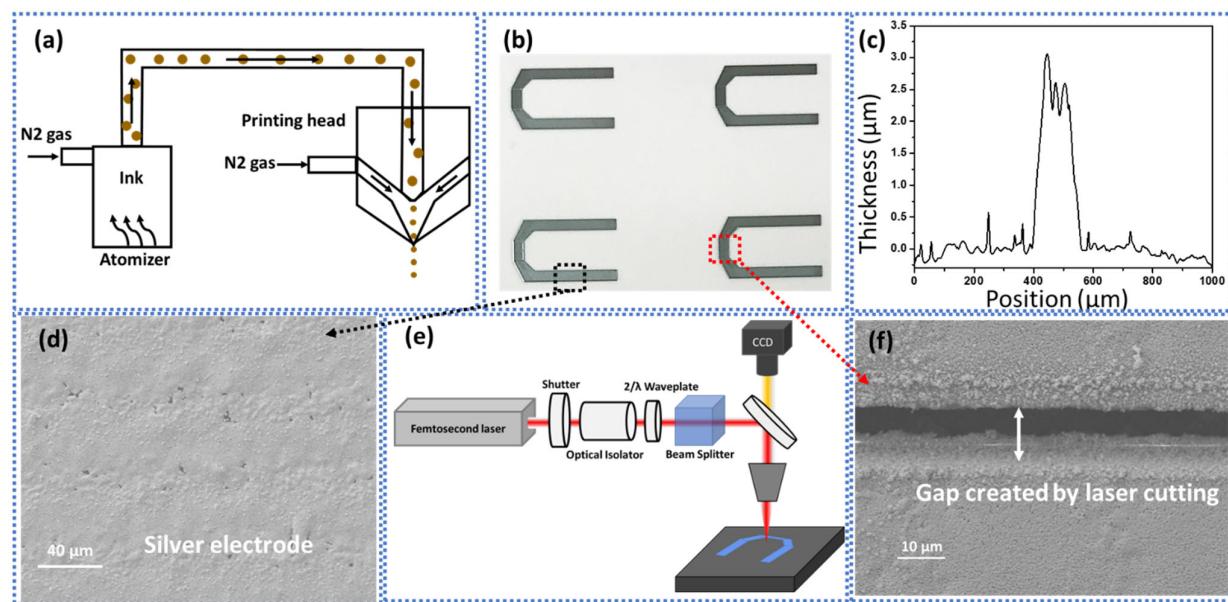
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**Figure S1.** SEM images of (a) synthesized Te nanotubes and an enlarged SEM image of Te nanotubes in the inset to Fig. s1(a); (b) the distribution of nanotube's diameter, and (c) XRD analyses for synthesized Te nanotubes.



**Figure S2.** (a) Schematic of the aerosol jet printing process, (b) an image of silver electrodes printed by aerosol jet printing, (c) the thickness measurement result for the silver electrode, (d) an SEM image of printed silver electrode's surface after curing(e) the schematic of the laser-procressing setup, and (f) an SEM image of the gap created by laser cutting process.